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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/591,437	06/09/2000	Jiuzhi Xue	DIS-P016	3249	
27313 7	590 12/14/2004		EXAMINER		
MARSH FISO	CHMANN & BREYI	DUONG, THOI V			
3151 S. VAUG	HN WAY	ADTIBUT	DADED MUMBED		
SUITE 411		ART UNIT	PAPER NUMBER		
AURORA, CO	O 80014	2871			
		DATE MAILED: 12/14/2004			

Please find below and/or attached an Office communication concerning this application or proceeding.

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•		Application	n No.	Applicant(s)		
Office Action Summary		09/591,43	7	XUE ET AL.		
		Examiner		Art Unit		
		Thoi V Duo		2871		
The Period for Rep	MAILING DATE of this communica V	tion appears on the	cover sheet with the c	orrespondence address		
A SHORTE THE MAILIN - Extensions of after SIX (6) M - If the period fc - If NO period fc - Failure to repl Any reply rece	NED STATUTORY PERIOD FOR IGNORY DERIOD FOR IGNORY DESCRIPTION OF THIS COMMUNICATION of SHORY SPECIFICATION OF THE COMMUNICATION OF THE	ATION. 37 CFR 1.136(a). In no eve cation. lays, a reply within the statu ory period will apply and wil, by statute, cause the appli	nt, however, may a reply be tin tory minimum of thirty (30) day I expire SIX (6) MONTHS from cation to become ABANDONE	nely filed rs will be considered timely. the mailing date of this communication. ED (35 U.S.C. § 133).		
Status				•		
1)⊠ Respo	onsive to communication(s) filed	on <u>04 December 20</u>	<u>003</u> .			
2a)☐ This a						
3)☐ Since						
closed	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of	Claims					
4a) Of 5)⊠ Claim 6)⊠ Claim 7)⊠ Claim	Claim(s) 1-26 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. Claim(s) 13 is/are allowed. Claim(s) 1-10,12 and 14-26 is/are rejected. Claim(s) 11 is/are objected to. Claim(s) are subject to restriction and/or election requirement.					
o)L Claim	(s) are subject to restricted	on and/or election re	equirement.			
Application Pa	pers					
•	pecification is objected to by the E					
-	rawing(s) filed on is/are: a			•		
7.7	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under	35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
Attachment(s)						
1) Notice of Re	ferences Cited (PTO-892)		4) Interview Summary			
3) Information [nftsperson's Patent Drawing Review (PTC Disclosure Statement(s) (PTO-1449 or PT Mail Date	•	Paper No(s)/Mail Do Notice of Informal F Other:	ate Patent Application (PTO-152)		

DETAILED ACTION

In view of the Appeal Brief filed December 04, 2003, PROSECUTION IS
 HEREBY REOPENED. A new ground of rejection is set forth below.

To avoid abandonment of the application, appellant must exercise one of the following two options:

- (1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,
 - (2) request reinstatement of the appeal.

If reinstatement of the appeal is requested, such request must be accompanied by a supplemental appeal brief, but no new amendments, affidavits (37 CFR 1.130, 1.131 or 1.132) or other evidence are permitted. See 37 CFR 1.193(b)(2).

2. Claims 1-26 are currently pending in this application.

Claim Objections

3. Claim 11 is objected to because of the following informalities: claim 11 recites the limitation "said continuous variation of the optical state of the light output" in line 2. There is insufficient antecedent basis for this limitation in the claim. Appropriate correction is required.

Claim Rejections - 35 USC § 112

4. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

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5. Claim 25 is rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. The claim contains the limitation "wherein the ferroelectric liquid crystal material in the optical device is surface stabilized" which is failed to comply with the enablement requirement. According to USPN 6,141,076, Liu appears to disclose an optical device having a similar structure and alignment treatment with the claimed invention; therefore, it would have been obvious to one having ordinary skill in the art to expect the same results as the claimed invention. Since Liu's disclosure, which directs to a non-surface-stabilized ferroelectric liquid crystal, has been patented, Liu's disclosure presumes valid over the claimed invention.

Claim Rejections - 35 USC § 103

- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 7. Claims 1, 3-10, 14, 16-24 and 26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al. (USPN 4,778,259).

Re claims 1 and 14, as shown in Figs. 1 and 4, Liu discloses an optical device (as well as a method for preventing formation of chevron structures in the optical device) including a ferroelectric liquid crystal material 16, said optical device comprising:

a first substrate 10 and a second substrate 11;

a first alignment treatment applied to a surface of the first substrate, said first alignment treatment being intended to induce an orientation of at least a portion of said ferroelectric liquid crystal material along a first alignment direction 25 and with a first pretilt angle "alpha1" with respect to a plane parallel to said first substrate (Fig. 4 and col. 3, line 35 through col. 4, line 60);

a second alignment treatment applied to a surface of the second substrate, said second alignment treatment being intended to induce an orientation of at least another portion of said ferroelectric liquid crystal material along a second alignment direction 26 and with a second pretilt angle "alpha2" with respect to a plane parallel to said second substrate (Fig. 4 and col. 3, line 35 through col. 4, line 60),

wherein the first substrate is located with respect to the second substrate in such a way that the surfaces of the first and second substrates onto which the first and second alignment treatments were applied, respectively, are spaced apart, generally parallel and facing each other and a projection of the first alignment direction onto the treated surface of the first substrate makes a non-zero angle "omega" (or Liu's buffing angle) with respect to a projection of the second alignment direction onto the treated surface of the first substrate such that, said ferroelectric liquid crystal material being injected between the first and second substrates (Figs. 3A, 3B and 4; col. 4, lines 4-60).

Liu discloses a problem in Prior Art where a typical SSFLC (surface-stabilized ferroelectric liquid crystal) creates a "chevron" structure which resulted in a high transmission loss due to strong buffing when parallel rubbing is applied to the

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substrates (col. 1, lines 25-34 and col. 4, lines 36-46). Liu overcomes the problem by providing a ferroelectric liquid crystal structure wherein excellent contrast is obtained with weak buffing or even greater contrast provided with strong buffing (col. 4, lines 47-53). Accordingly, it is obvious that Liu creates a structure free of chevron without the need to otherwise apply an additional treatment to the optical device since buffing (weak or strong) is the only treatment in the optical device of Liu et al. to overcome a chevron or a quasi-bookshelf generated in parallel alignment case in some traditional configurations. In addition, Liu et al. also discloses that the buffing angles of the substrates are at an angle, with respect to one another, of less than 90 degrees, preferably at about 45 degrees (col. 4, lines 53-60). Accordingly, Liu also creates a cross-buffed optical device.

Re claims 3 and 16, said ferroelectric liquid crystal material has a cone angle "theta", said non-zero angle "omega" has a predetermined value such that "omega" >= 2(theta) and "omega" is different from 180 degrees (col. 4, lines 53-60).

Re claims 4, 17 and 21, said first and second alignment treatments are specifically chosen so as to specifically induce pretilt angles of "alpha1" and "alpha2" (Liu's angle theta 0) respectively (Fig. 4 and col. 4, lines 23-26), wherein said choosing step further includes the step of taking into consideration molecular anchoring propeties of said first and second alignment treatments so as to choose first and second alignment treatments to specifically induce pretilt angles of "alpha 1" and "alpha 2", respectively, while providing strong molecular anchoring of at least portions of the

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ferroelectric liquid crystal material located immediately adjacent to the treated surfaces of the first and second substrates (col. 3, lines 36-45 and col. 4, lines 46-66).

Re claims 5 and 18, said first alignment treatment includes a coating of a selected alignment material, said coating being applied, cured and treated so as to specifically induce the pretilt angle of "alpha1" (col. 3, lines 31-45).

Re claims 6 and 19, said second alignment treatment includes a coating of another selected alignment material, said coating being applied, cured and treated so as to specifically induce the pretilt angle of "alpha2" (col. 3, lines 31-45 and col. 4, lines 23-26).

Re claims 8 and 20, said first and second alignment treatments are generally identical (col. 3, lines 31-45).

Re claim 7, each of said pretilt angles is between about 3 degrees and about 7 degrees (col. 8, lines 36-44); and

Re claim 9, said first and second alignment treatments provide strong molecular anchoring of at least portions of the ferroelectric liquid crystal material located immediately adjacent to the treated surfaces of the first and second substrates (col. 4, lines 46-52).

Re claims 10 and 22, as shown in Figs. 10A and 10B, an optical device of Liu further comprises a light input 1018 directed at said optical device in such a way that the optical device in turn produces a light output of a particular optical state; and means 1022 for electrically addressing said optical device in such a way that the particular

optical state of the light output is continuously variable between a minimum optical state (V-) and a maximum optical state (V+).

Re claims 23 and 24, Liu discloses that the first and second pretilt angles are non-zero (col. 4, lines 23-26 and col. 8, lines 42-44).

Re claim 26, Liu discloses an optical device comprising all limitations of claim 1, wherein the first and second substrates are spaced apart by a distance sufficiently small to suppress formation of helixes typically formed of the ferroelectric liquid crystal material (col. 3, lines 50-57).

8. Claims 2, 12 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al. (USPN 6,141,076) in view of Iwayama et al. (USPN 5,323,253).

Liu et al. discloses an optical device that is basically the same as that recited in claims 2, 12 and 15 except for a reflective display surface and a phase sequence of the ferroelectric liquid crystal material.

As shown in Fig. 3, Iwayama et al. discloses a ferroelectric liquid crystal device comprising a reflective display surface formed on a substrate (col. 5, lines 16-20), wherein the liquid crystal shows a phase sequence of Isotropic – Nematic - Smectic A - Smectic C* - Crystalline states (col. 5, lines 52-59).

Thus, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the optical device of Liu et al. with the teaching of Iwayawa et al. by forming a reflective surface for a reflective display and employing a ferroelectric liquid crystal material having a phase sequence of Isotropic – Nematic -

Smectic A - Smectic C* - Crystalline states for avoiding the change in cell thickness and the occurrence of liquid crystal void (col. 5, lines 64-68).

Allowable Subject Matter

- 9. Claim 11 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims (see Reasons for Allowance below).
- 10. Claim 13 is allowed.

The following is an examiner's statement of reasons for allowance: none of the prior art of record fairly suggests or shows all of the limitations as claimed. Specifically,

None of the prior art of record discloses, in combination with other limitations as claimed, an optical device including a ferroelectric liquid crystal material having free of chevron structures without a need to otherwise apply an additional treatment to the optical device, wherein an optical retardance of the optical device remains generally constant during continuous variation of the optical state of the light output.

The most relevant reference, USPN 6,141,076 of Liu et al., fails to disclose or suggest a constant optical retardance of the optical device remained during continuous variation of the optical state of the light output. As shown in Figs. 10A and 10B, the Liu et al.'s reference only discloses that the particular optical state of the light output is continuously variable between a minimum optical state (V-) and a maximum optical state (V+) (col. 5, lines 40 through col. 6, line 12).

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Response to Arguments

11. Applicant's arguments filed December 04, 2003 have been fully considered but they are not persuasive.

Group A (Claims 1-10, 12 and 14-24): Applicant argued that Liu does not disclose a crossed-buffed device and a ferroelectric liquid crystal material being free of chevron structures without the need to otherwise apply an additional treatment to the optical device.

The Examiner disagrees with the Applicant's remarks since Liu discloses a problem in Prior Art where a typical SSFLC (surface-stabilized ferroelectric liquid crystal) creates a "chevron" structure which resulted in a high transmission loss due to strong buffing when parallel rubbing is applied to the substrates (col. 1, lines 25-34 and col. 4, lines 36-46). Liu overcomes the problem by providing a ferroelectric liquid crystal structure wherein excellent contrast is obtained with weak buffing or even greater contrast provided with strong buffing (col. 4, lines 47-53). Accordingly, it is obvious that Liu creates a structure free of chevron without the need to otherwise apply an additional treatment to the optical device since buffing (weak or strong) is the only treatment in the optical device of Liu et al. to overcome a chevron or a quasi-bookshelf generated in parallel alignment case in some traditional configurations. In addition, Liu et al. also discloses that the buffing angles of the substrates are at an angle, with respect to one

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another, of less than 90 degrees, preferably at about 45 degrees (col. 4, lines 53-60).

Accordingly, Liu also creates a cross-buffed optical device.

Group D (claim 26): Applicant argued that the limitation "sufficiently small spacing

to suppress formation of helixes" is not found in Liu.

The Examiner disagrees since, as shown in Figs. 2A-2C, Liu discloses that the

cell thickness 212 is designed to be thin and the surface anchoring is strong for

suppressing formation of helixes (col. 3, lines 50-57).

Conclusion

12. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Thoi V. Duong whose telephone number is (571) 272-

2292. The examiner can normally be reached on Monday-Friday from 8:30 am to 4:30

pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Robert Kim, can be reached at (571) 272-2293.

Thoi Duong

,

11/26/2004

ROBERT H. KIM
SUPERVISORY PATENT EXAMINER

TECHNOLOGY CENTER 2800

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